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App	lication/Control No.
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Examiner Kwang Han

OH ET AL. Art Unit 1795

Applicant(s)/Patent Under Reexamination

ORIGINAL					INTERNATIONAL CLASSIFICATION								
CLASS SUBCLASS							С	LAIMED		NON-CLAIMED			
		188		н	0	1	М	6 / 16 (2006.0)					
ODOGO PEEEDENGE(C)			Н	0	1	М	4 / 58 (2006.0)						
GROSS REFERENCE(S)				н	0	1	М	6 / 04 (2006.01.01)					
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⊠	Claims renumbered in the same order as presented by applicant				☐ CPA ☐ T.D.				☐ R.1.47						
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/Kwang Han/ Examiner.Art Unit 1795	4/24/09	ns Allowed:			
(Assistant Examiner)	(Date)	73			
/Dah-Wei D Yuan/ Supervisory Patent Examiner.Art Unit 1795	04/24/2009	O.G. Print Claim(s)	O.G. Print Figure		
(Primary Examiner)	(Date)	1	9		